



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 9938  
Hiroshi TAKANASHI et al. : Docket No. 2001\_0476  
Serial No. 09/838,118 ✓ : Group Art Unit 1752  
Filed April 20, 2001 : Examiner S. Lee

13/12  
RECEIVED  
SEP 25 2003  
TC 1700

NEGATIVE-WORKING PHOTSENSITIVE  
RESIN COMPOSITION AND  
PHOTSENSITIVE RESIN PLATE  
USING THE SAME

**RESPONSE UNDER 37. CFR 1.116  
EXPEDITED PROCEDURE  
EXAMINING GROUP 1752.**

**RESPONSE UNDER 37 C.F.R. 1.116**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated March 20, 2003, the period for response having been extended for three months by the attached petition, please amend the present application as follows: